

Test results of electro-polishing for quarter-wave resonators



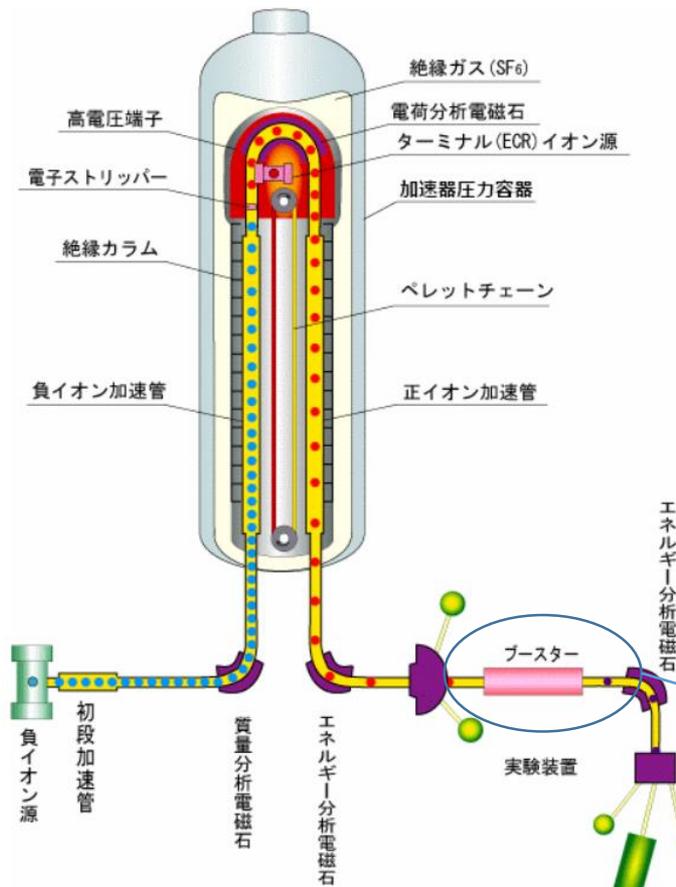
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TTC 2022 meeting
WG2
11-14 October 2022

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Tokai Tandem Accelerator

<https://ttandem.jaea.go.jp/index.html>



Tokai Tandem Accelerator of JAEA

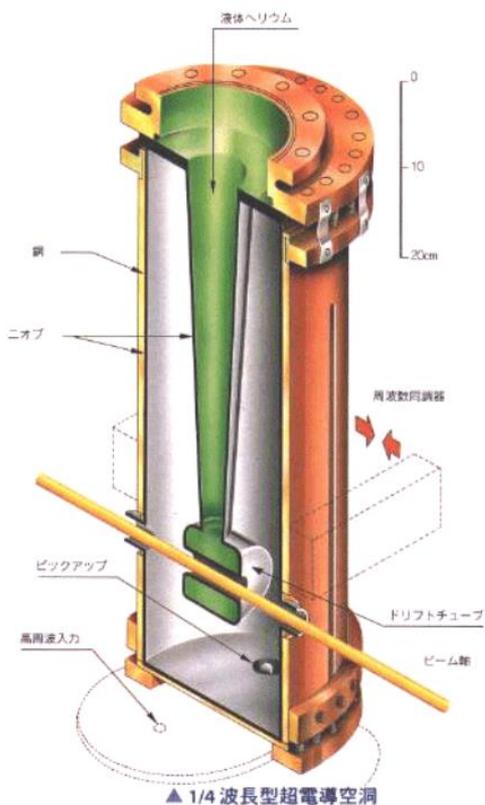


Superconducting booster

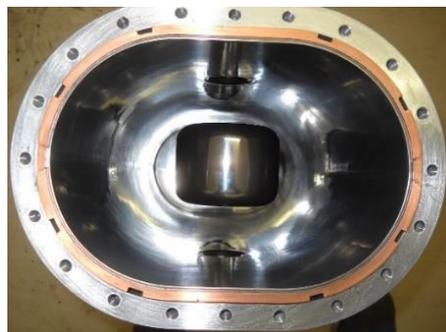
At the Tokai Tandem Accelerator of JAEA, research on nuclear physics, nuclear chemistry, material irradiation, etc. using heavy ion beams is being conducted. A superconducting booster has been installed in the latter part of the tandem to increase the beam energy by 2 to 3 times, but it has been out of service for a long time. The specifications of this superconducting booster are model = coaxial 1/4 wavelength resonator (QWR), frequency is 130MHz, optimum beam velocity = 10% of the light velocity, and acceleration electric field = 5.0MV / m @ 4W.

Introduction

1-2 Quarter-wave resonators (QWR)



Quarter wave resonators
(Outside : copper
Inside : Niobium)

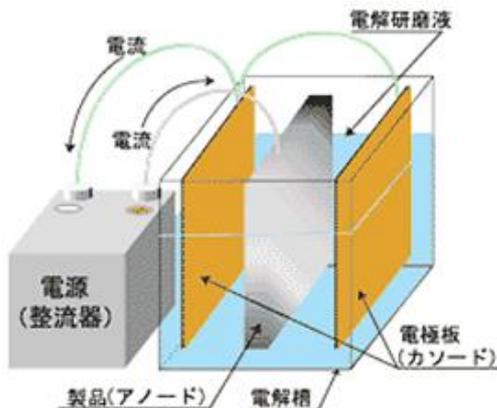


A spare cavity used for experiments (L42)

Currently, we are working on restarting, and we are considering electro-polishing of the preliminary superconducting cavity in preparation for conducting various tests. This cavity is made of a niobium-copper clad plate and has a large opening at the bottom, which allows it to be electro-polished again.

Marui Galvanizing Co., Ltd. and Japan Atomic Energy Agency jointly examined the equipment and conditions for 1/4 wavelength type superconducting cavity inner surface electro-polishing, conducted electro-polishing, and evaluated the surface and cavity performance after polishing.

General method of EP (schematics)

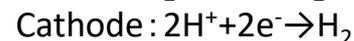


(Electro-polishing, EP for short)

A technology that dissolves and polishes the metal surface by electrolyzing the object (metal to be polished) as the anode in an electrolytic solution with a counter electrode (cathode).

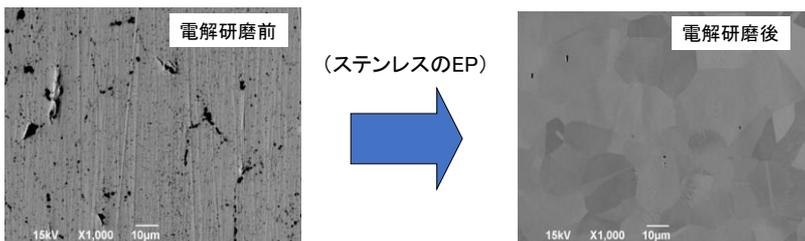
Improves surface flatness, corrosion resistance, and cleanliness.

General reaction of EP



(M: polished metal, n: atomic value)

How EP progresses (schematics)



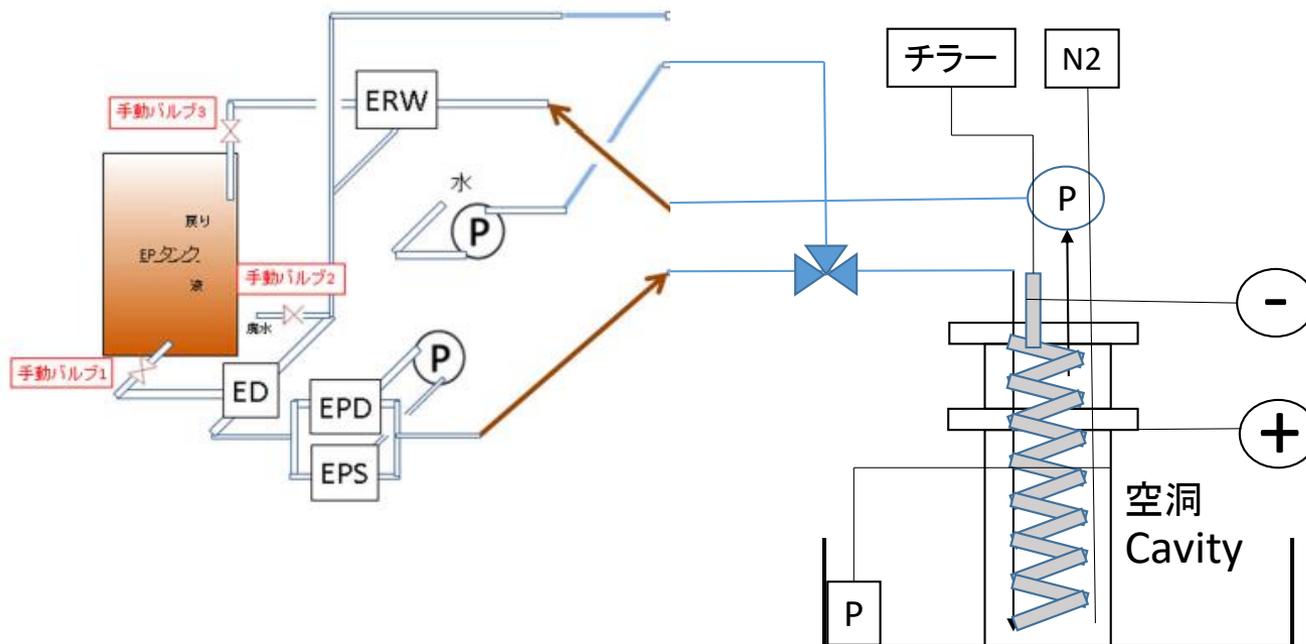
Since the protruding part of the product is close to the cathode, electricity flows easily and it melts easily. Since the amount of melting is proportional to the amount of electricity, the convex portion melts preferentially. As a result, the unevenness gradually disappears and the surface becomes flat.

Niobium cavity EP



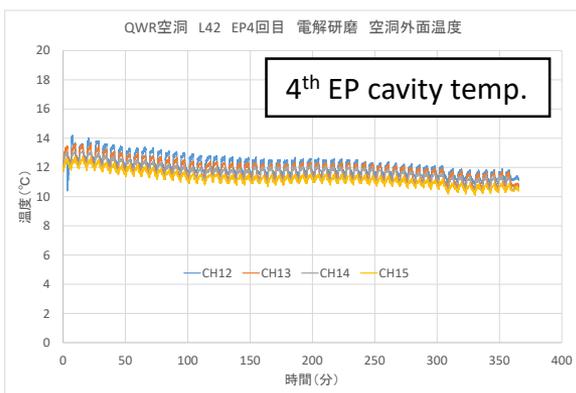
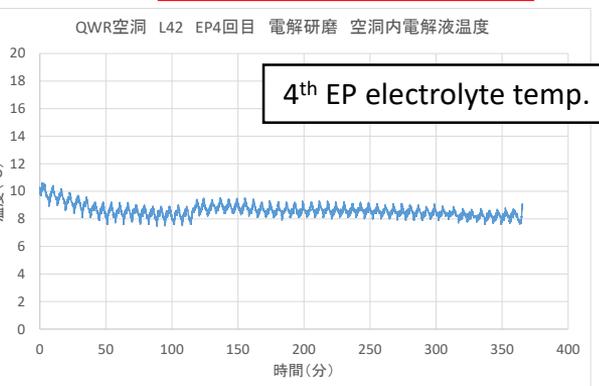
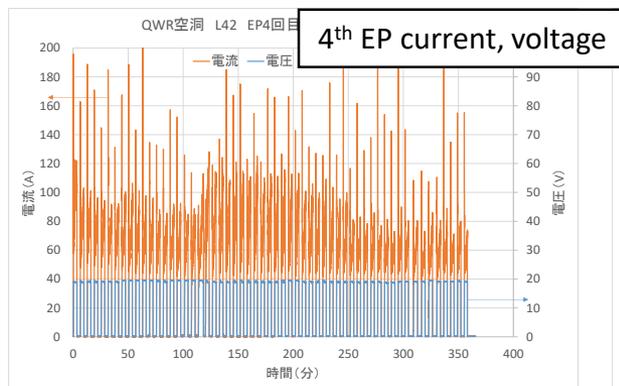
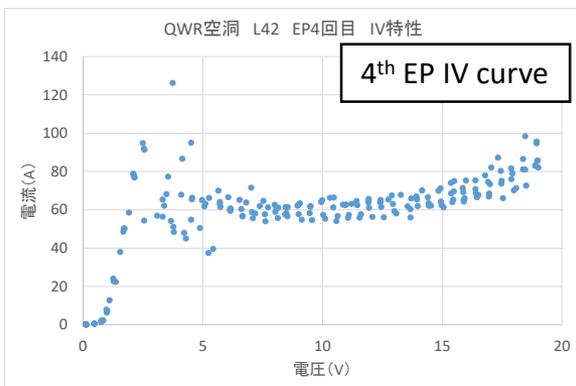
In 1.3GHz niobium superconducting cavities, electro-polishing is applied to the inner surface to improve cavity performance.

A schematic of EP setup



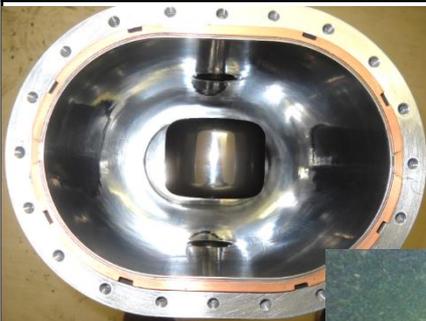
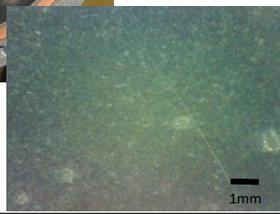
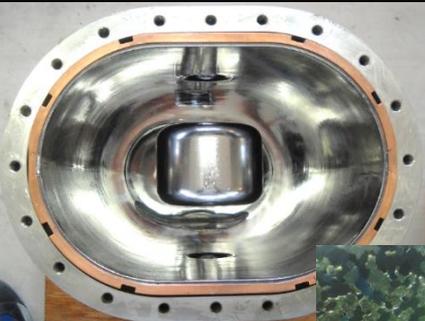
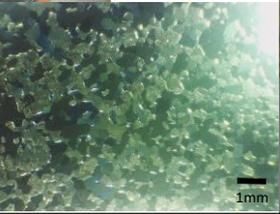
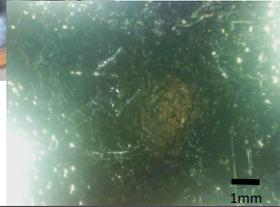
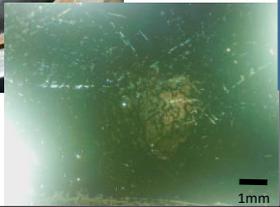
- Place the cavity with the opening facing up. Electrodes and electrolyte hoses were inserted through the openings.
- The electrolyte was circulated by a pump.
(Injected into the bottom of the cavity, recovered from the top)
- Cavity cooling by cooling water shower using vat and submersible pump
- There were no serious problems with the EP implementation.

| | 1 st EP | 2 nd EP | 3 rd EP | 4 th EP |
|-------------------------|--|---|--|---|
| Electrolyte | H ₂ SO ₄ (98%):HF(55%) =9:1(USED) | H ₂ SO ₄ (98%):HF(55%) =9:1(NEW) | H ₂ SO ₄ (98%):HF(55%) =9:1(USED) | H ₂ SO ₄ (98%):HF(55%) =9:1(NEW) |
| Voltage | ~18V | ~20V | ~20V | ~20V |
| Voltage apply | Continuous | 3min-ON/3min-OFF | Continuous | 3min-ON/3min-OFF |
| Cavity cooling | None | Done | Done | Done |
| N ₂ bubbling | None | Done | Done | Done |
| Target removal | 30μm | 20μm | 25μm | 25μm |

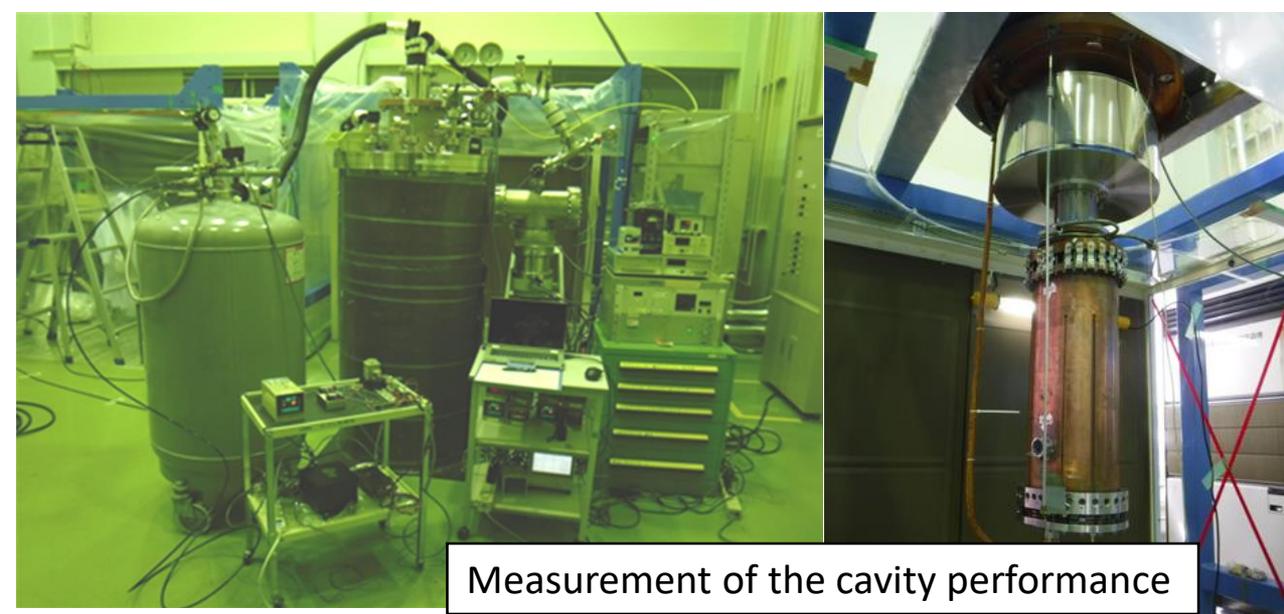


- 4 times EP (total removal 100μm) were performed using one cavity (L42).
 - The logged data of 4th EP is shown.
 - In IV curve, plateau region was shown around >5V.
 - Cavity temperature was around 10-14°C using water cooling.
 - Electrolyte temperature in the cavity was under 10 °C .
 - EP current was around 80 A.
- EP current, voltage, temperature were almost on target.

2-2 Results of EP (surface inspection and roughness)

| Before EP (Mechanical polish) | After 1 st EP | After 2 nd EP |
|---|--|---|
|   <p data-bbox="106 556 347 656">Ra = 0.11μm Rz = 1.21μm</p> |   <p data-bbox="705 556 946 656">Ra = 0.67μm Rz = 3.40μm</p> |   <p data-bbox="1313 556 1555 656">Ra = 0.48μm Rz = 2.53μm</p> |
| After 3 rd EP | After 4 th EP | A legend |
|   <p data-bbox="106 1092 347 1192">Ra = 0.47μm Rz = 2.24μm</p> |   <p data-bbox="705 1092 946 1192">Ra = 0.45μm Rz = 2.06μm</p> | <div data-bbox="1304 863 1632 906" style="border: 1px solid black; padding: 5px;">Digital camera photo</div> <div data-bbox="1603 1042 1796 1170" style="border: 1px solid black; padding: 5px;">Microscope photo (× 200)</div> <div data-bbox="1275 1106 1564 1185" style="border: 1px solid black; padding: 5px;">Surface roughness (Average of 4 points)</div> |

- After 1st EP, the surface roughness became worse (It seems that the conditions were not optimized).
- After 2nd – 4th EP, the surface roughness tended to improve (The conditions seem to have improved).
- After 4th EP, the surface became more glossy but roughness was larger than before EP.



Measurement of the cavity performance

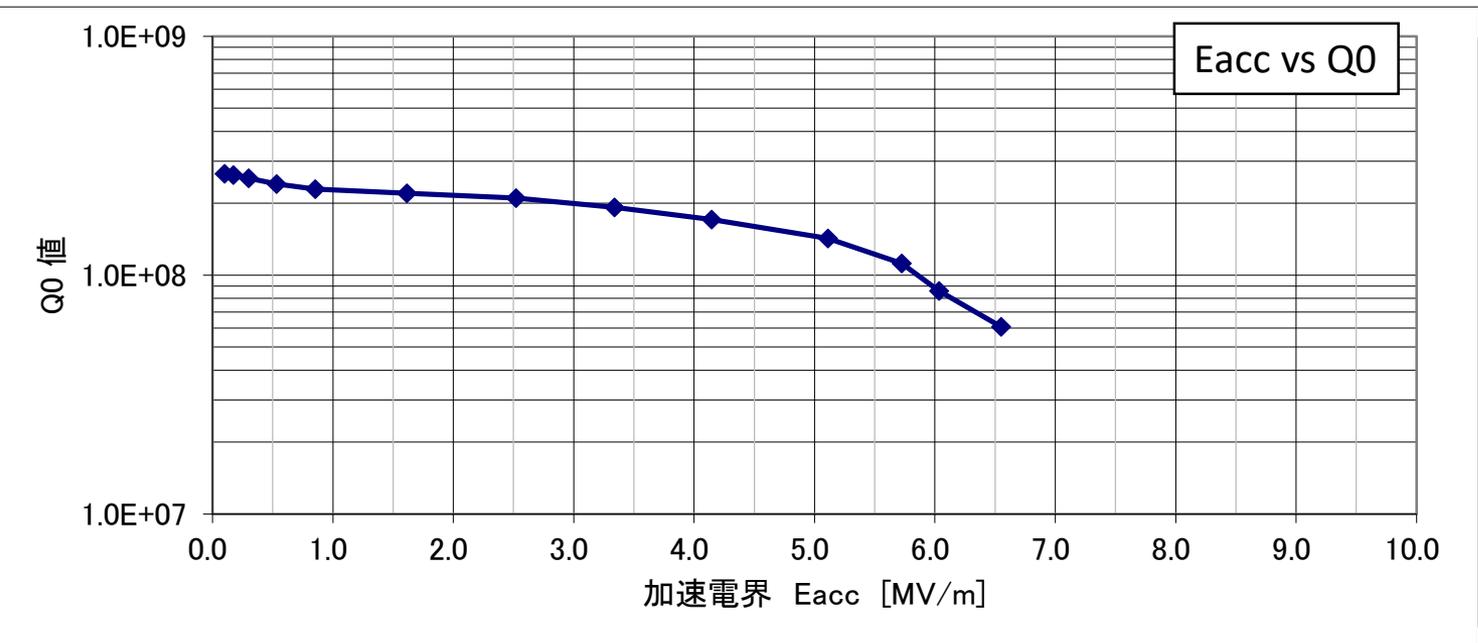
After Phase 1 EP, the cavity performance was measured at 4.2K.

↓

Low electric field Q_0 value was $2.7E8$ and the cavity performance was $4.2MV/m @4W$

↓

It did not reach the standard value ($5.0MV/m @4W$)



The main reason seems to be rough surface and high surface resistance.

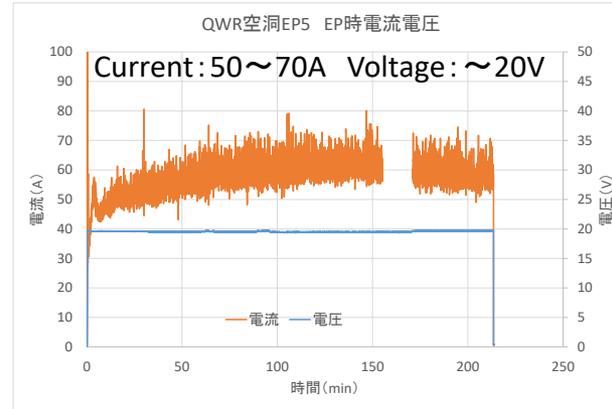
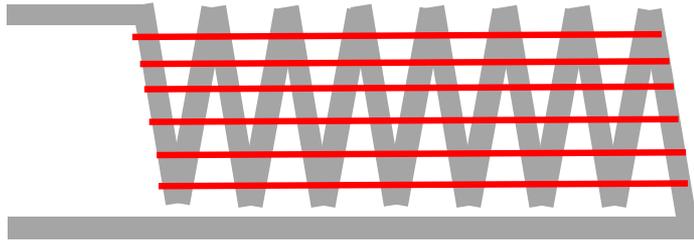
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It is necessary to review the EP conditions, electrodes, methods, etc.

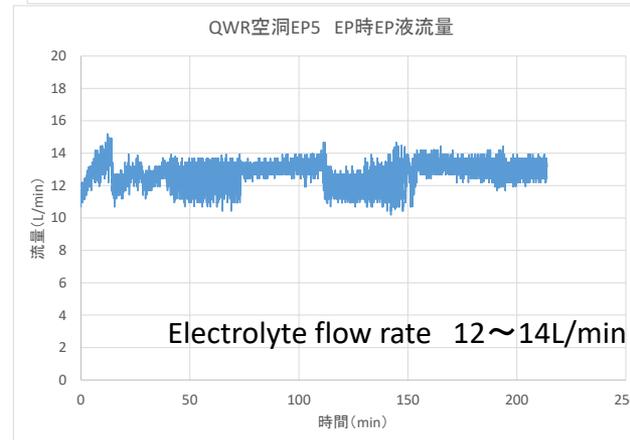
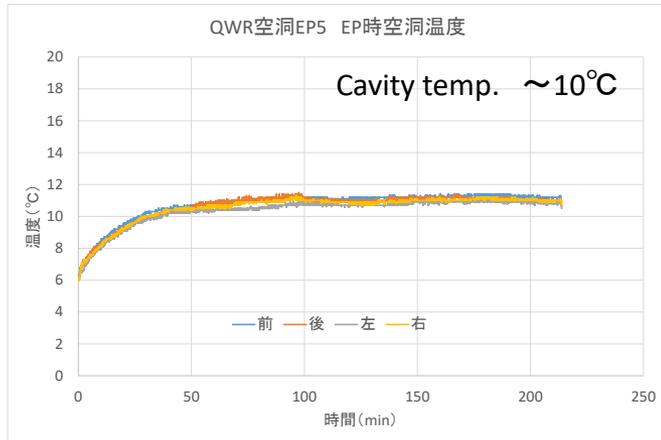
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Phase 2 EP experiments

A schematic of electrode, auxiliary electrode



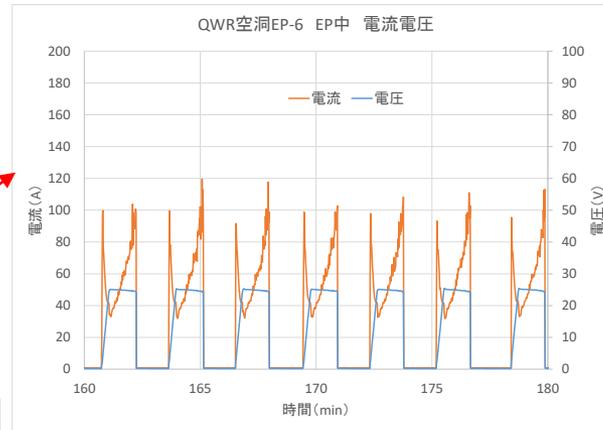
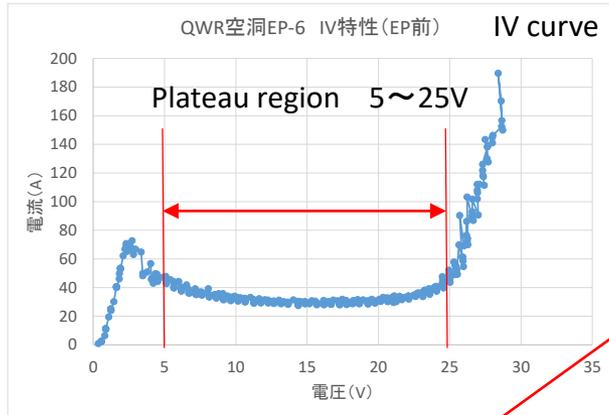
Inner surface after this EP



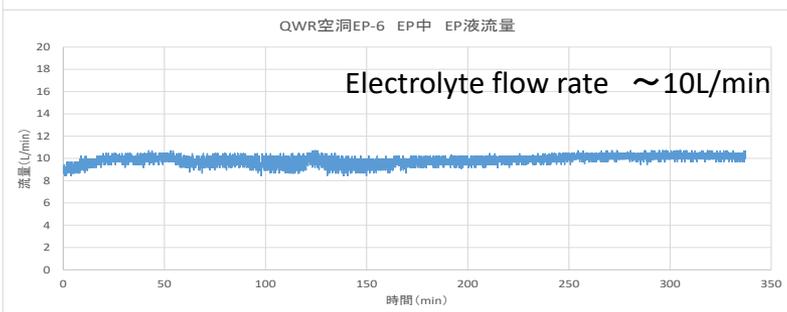
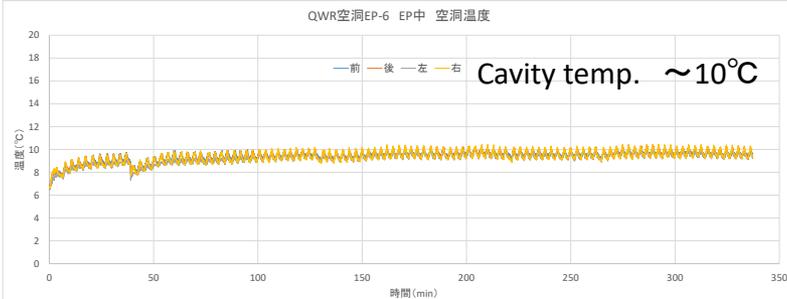
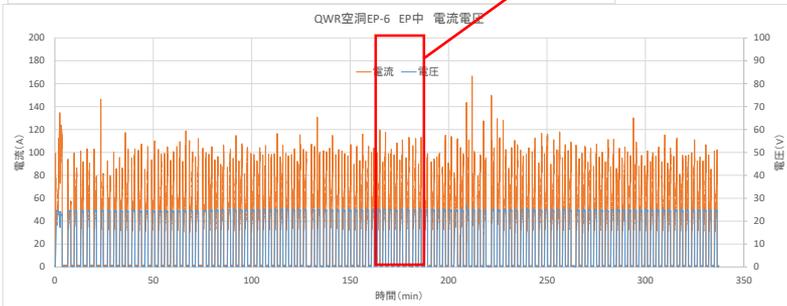
Average current comparison

| | Average current (ON) | Average cavity temperature | Average EP acid temperature | Voltage | Voltage application method | EP acid |
|----------------------|----------------------|----------------------------|-----------------------------|---------|----------------------------|---------|
| Phase1 1st | 125.4A | 34.9°C | 19.6°C | 18V | Semi-continuous | USED |
| Phase1 2nd | 47.4A | 10.1°C | 9.2°C | 20V | Intermittent | NEW |
| Phase1 3rd | 61.0A | 12.1°C | 11.1°C | 20V | Continuous | USED |
| Phase1 4th | 66.4A | 11.5°C | 8.6°C | 20V | Intermittent | NEW |
| Phase2 1st (this EP) | 57.3A | 10.6°C | 9.8°C | 20V | Continuous | NEW |

- An auxiliary electrode was added to the conventional electrode in order to increase the current density and improve the polished surface by increasing the cathode area. (Approx. 30% increase in electrode area, red line in the above schematic)
- No clear improvement was seen (details later).
→ There is no problem with the conventional electrode.



Current : 40~100A
Voltage : ~25V
1min-ON/1min-OFF



Inner surface after this EP

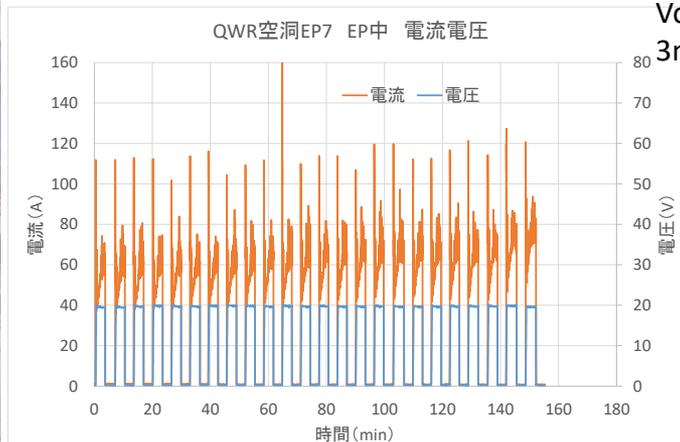


- To confirm the range of the plateau region, the IV characteristics were confirmed from 0 to 30V.
- An increase in current was observed from 25V in the IV curve.
- 5~25 V is set as the plateau region from the shape of the curve and EP was performed at 25V that is the upper limit of the plateau.
- No clear improvement was seen (details later).
- There is no problem with the conventional 20V.

EP experiment (Phase 2) 3-3 EP acid flow rate and agitation increase TTCM2022 WG2, K.Nii – 12/16

Current: 40~80A
Voltage: ~20V
3min-ON/3min-OFF

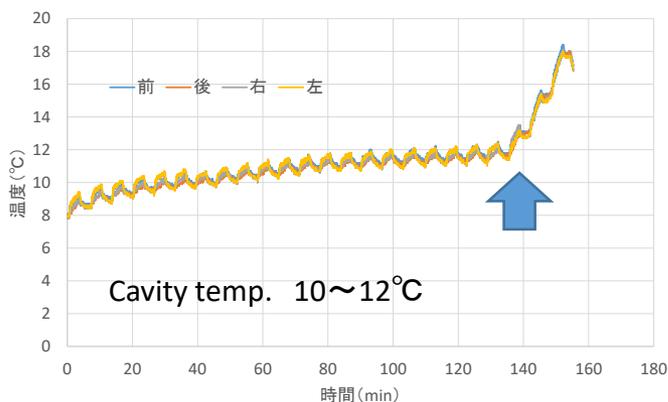
Shake the cavity by hand during EP



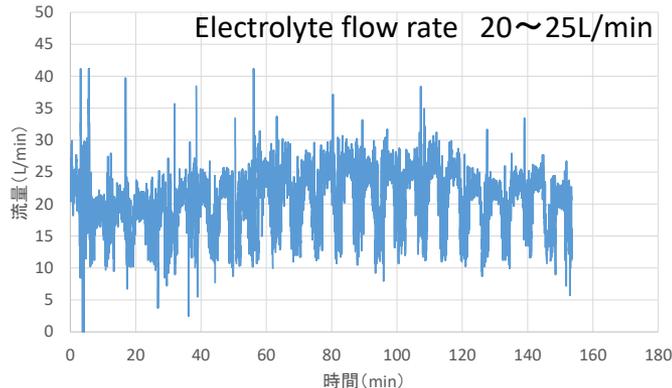
Inner surface after this EP



QWR空洞EP7 EP中 空洞温度



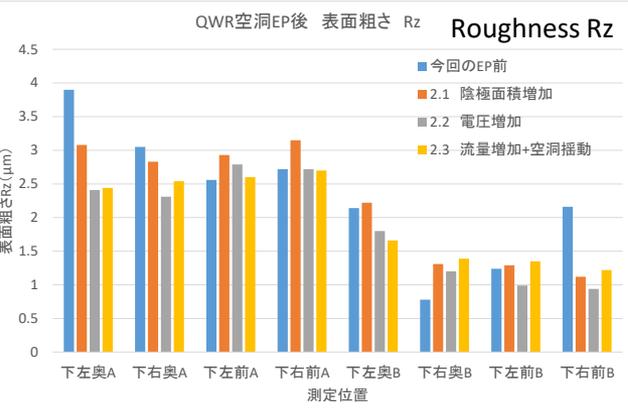
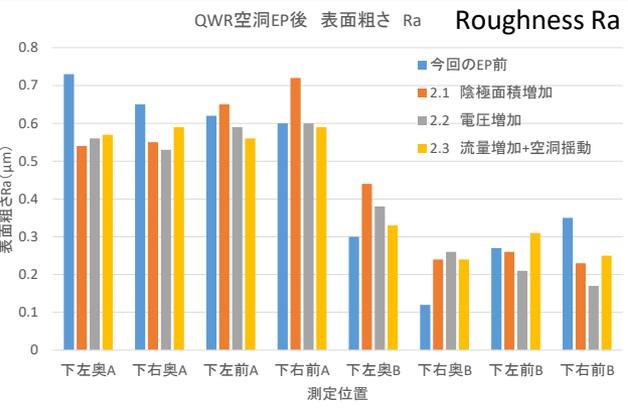
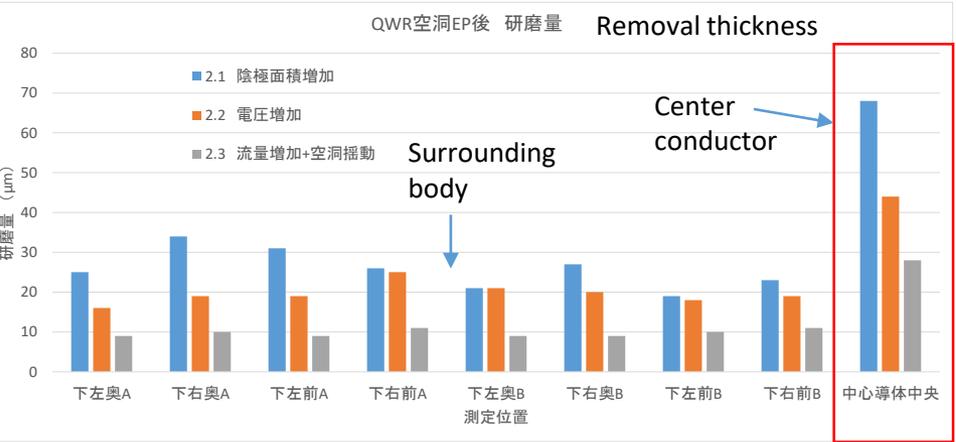
QWR空洞EP7 EP中 EP液流量



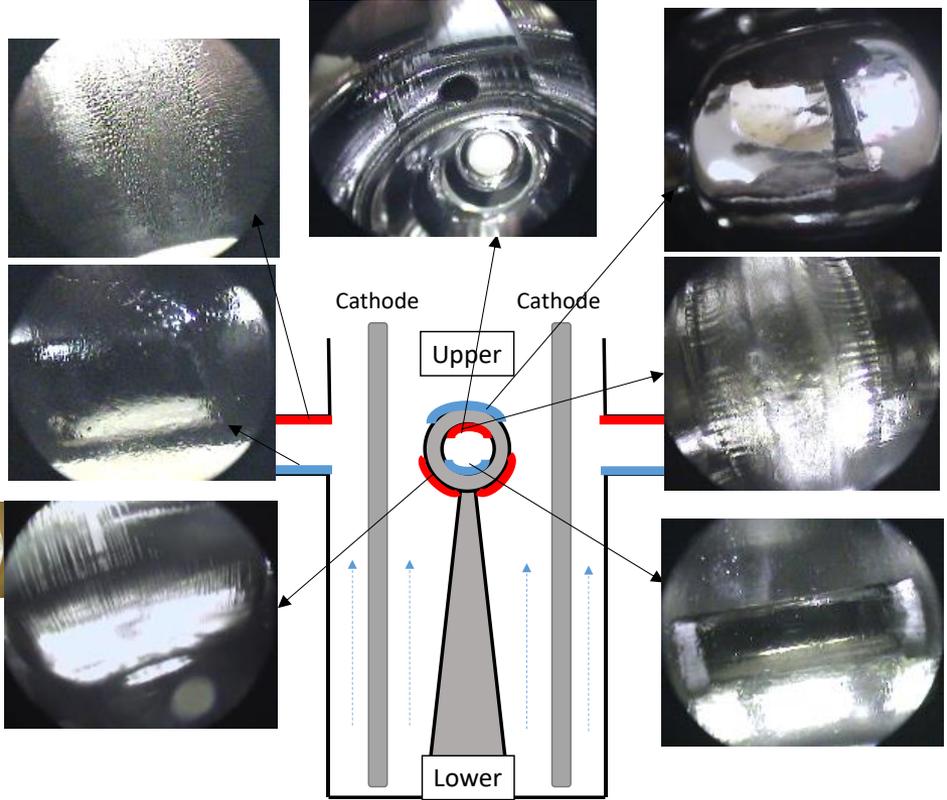
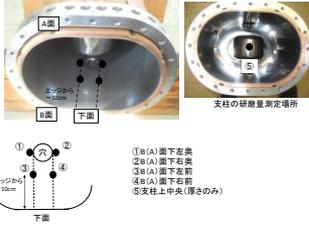
- Electrolyte flow rate was increased to ~20L/min and it was shaken by shaking the cavity by hand to improve agitating effect during EP.
- EP was stopped due to temperature and odor abnormalities during EP. The cause was that the center conductor had a hole and the electrolyte was leaking into the cavity cooling water.

EP experiment (Phase 2) 3-4 Removal thickness, surface inspection and roughness

Endoscope inspection (After all EP)



Measurement points



Results of removal and roughness evaluation

- The removal thickness of center conductor is 2-3 times larger than that of body part.
- The surface roughness has no proper tendency and has not changed significantly in case of phase 2 EP.

Results of endoscope inspection

- Upward surfaces at EP (blue lines) were relatively flat and glossy.
- Downward surfaces at EP (red lines) were relatively rough and had bubble traces.

4 Summary and next step

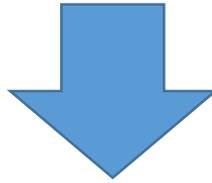
- The inner surface of the QWR (spare cavity) used for the superconducting booster of the Tokai tandem accelerator was re-polished by electro-polishing.
- Electro-polishing (EP) set-up and operation could be carried out without serious problems. A total of about 100 μm polishing was performed in Phase 1 experiments in four stages.
- Compared to before electro-polishing (surface after mechanical polishing), the surface gloss seemed to be improved, but the surface roughness value became worse.
- As a result of the cavity performance measurement in liquid helium (4.2K), the performance was 4.2MV/m@4W with a Q0 value of 2.7E8 at a low electric field. This did not reach the standard value (5.0MV/m@4W).
- Phase 2 experiments were conducted to improve the EP parameters. Electrode area, voltage, and agitation were examined, but no significant improvement was observed.
- The removal thickness of the center conductor was much larger than other parts, and a hole was opened during the Phase 2 experiment. No significant improvement in surface roughness was observed.
- The upward surface at EP was glossy, but the downward surface was rough with bubble traces.

4 Summary and next step

Next step

It is necessary to...

- Suppress bubble diffusion and internal accumulation to improve inner surface.
- Investigate the cause of uneven removal and state of electrolysis.



for that purpose...

- Confirmation of cavity oscillation, electrolyte stirring and agitation effect
- Review of electrode shape and improvement of bubble cover
- Improvement of electrolyte flow method
- Optimization of voltage ON/OFF application conditions

Thank you for your attention.

